

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

FEB 0 7 2005

Applicant: Yuanning Chen, et al.

Art Unit: 2813

Serial No.: 10/719,280

Examiner: Jack S.J. Chen

Filed: 11/21/03

Docket: TI-35022.1

For: Use of Hafnium Silicon Oxynitride as the Cap Layer of the Sidewall Spacer

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Dear Sir:

CERTIFICATION OF FACSIMILE TRANSMISSION

I hereby certify that the above correspondence is being transmitted by facsimile to the U.S. Patent and Trademark Office at 703-872-9306 on the date shown below.

Karen Vert 2-7-05
(Aren Vertz Date

EXTENSION OF TIME

Pursuant to 37 CFR 1.136(a), Applicants respectfully petition the Commissioner for an extension of the shortened statutory period for response in the above-identified Application. The fee for this extension is indicated below:

__X First Month (\$120)
___ Second Month (\$450)
___ Third Month (\$1,020)
___ Fourth Month (\$1,590)

_____ Fifth Month (\$2,160)

Please charge the fee to deposit account No. 20-0668 of Texas Instruments Incorporated. The Commissioner is hereby authorized to charge any fees which may be required, or credit any overpayment to Account No. 20-0668. An original and two copies of this sheet are enclosed

Respectfully submitted

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